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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

MARKUS NOPPER

AXEL PREUSSE

Serial No.: 10/602,192

Filed: June 24, 2003

Mail Stop Amendment

P.O. Box 1450

Sir:

Commissioner for Patents

Alexandria, VA 22313-1450

For: METHOD OF FORMING A METAL

LAYER OVER A PATTERNED DIELECTRIC BY ELECTROLESS DEPOSITION USING A CATALYST Examiner: Caridad Everhart

Group Art Unit: 2825

Att'y Docket: 2000.106500/DE0260

Customer No.: 23720

RESPONSE TO OFFICE ACTION DATED FEBRUARY 11, 2005

CERTIFICATE OF MAILING 37 C.F.R 1.8

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the date below:

April 12, 2005

Date

ate //au/au/au/signature

This paper is submitted in response to the Office Action dated February 11, 2005, for which the three-month date for response is May 11, 2005.

No fees are believed to be due in connection with the present paper. However, should any fees be required under 37 C.F.R. §§ 1.16 to 1.21, the Director is authorized to deduct such fees from the Advanced Micro Devices, Inc. Deposit Account No. 01-0365/DE0260. In the event the monies in that account are insufficient, the Director is authorized to withdraw funds from Williams, Morgan & Amerson, P.C. Deposit Account No. 50-0786/2000.106500.

Reconsideration of the application in view of the following amendments and remarks is respectfully requested.